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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Reissue Application of

Kenji NISHI

Group Art Unit: 2851

Application No.: 09/779,686

Examiner: A. Mathews

Filed: February 9, 2001

Docket No.: 110157.98

For: PROJECTION EXPOSURE APPARATUS

AMENDMENT IN REISSUE APPLICATION

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

In reply to the September 25, 2002 Office Action, the shortened statutory period for reply being extended by the attached Petition for Extension of Time, please amend the above-identified application as follows:

IN THE SPECIFICATION:

Column 1, before the first line of the specification, after the title of the invention, please insert a new paragraph as follows:

C1
--This is one of three (3) reissue applications directed to various aspects of a projection exposure method and apparatus described in U.S. Patent No. 5,477,304, which corresponds to U.S. Patent Application No. 08/377,504 filed January 25, 1995, which is a continuation of U.S. Patent Application No. 08/139,803 filed October 22, 1993 (now abandoned). The first filed reissue application is U.S. Patent Application No. 08/994,758 filed December 19, 1997. The other two reissue applications are divisional applications of U.S. Patent Application No. 08/994,758. The serial number and filing date of the two